

REMARKS

This application has been carefully reviewed in light of the Office Action dated March 30, 2006. Claims 1 to 8 are in the application, with Claim 1 being independent. Reconsideration and further examination are respectfully requested.

Two replacement drawing sheets are being submitted herewith, which include changes required by the Office Action. In particular, a --Prior Art-- legend has been added to each of Figures 8 and 9.

The Office Action does not acknowledge receipt of the certified copy of the Japanese priority application, for the reason that the certified copy was not available in the Image File Wrapper system. Applicants note that the certified copy is now available. Accordingly, acknowledgment of receipt of the certified copy is respectfully requested.

Claims 1 to 6 were rejected under 35 U.S.C. § 102(b) or, in the alternative, under 35 U.S.C. § 103(a) over U.S. Patent No. 4,536,607 (Wiesmann). Claims 1 to 6 were rejected under 35 U.S.C. § 102(b) or, in the alternative, under 35 U.S.C. § 103(a) over Japan 63-77167 (JP '167). Claims 1 to 6 and 8 were rejected under 35 U.S.C. § 102(b) or, in the alternative, under 35 U.S.C. § 103(a) over JP 61-1062 (JP '062). Claims 1 to 8 were rejected under 35 U.S.C. § 103(a) over JP '167 in view of U.S. Patent No. 4,971,919 (Yamazaki). These rejections are respectfully traversed.

According to a feature of the invention as recited by Claim 1, the selective reflection layer has a sheet resistance of $100\text{ k}\Omega/\square$ or more and $100\text{ M}\Omega/\square$ or less

The Office Action states that this feature is inherent in Wiesmann, JP '167, and JP '062. Applicants respectfully disagree.

The Office Action takes the position that the following layers correspond to the selective reflection layer of the present invention: ITO layer (18) or indium oxide layer (28) in Wiesmann; ITO layer (7) in JP '167, and tin oxide layer (14a) in JP '062. However, it is Applicants' understanding that the sheet resistance of each of these layers is lower than that recited in instant Claim 1. The sheet resistance of ITO, indium oxide, tin oxide, or the like generally ranges from several Ω/\square to several hundred Ω/\square , unless it is subjected to a treatment that changes its sheet resistance.

To establish inherency, the extrinsic evidence must make clear that the missing descriptive matter is necessarily present in that which is described in the reference. The fact that the missing descriptive matter may result from a set of circumstances is not sufficient. See MPEP § 2112. Applicants respectfully submit that such evidence is not provided by the Office Action.

Nothing in Yamazaki is seen to remedy the foregoing deficiencies of Wiesmann, JP '167, and JP '062.

Claims 1 to 8 were rejected under 35 U.S.C. § 102(e) or, in the alternative, under 35 U.S.C. § 103(a) over U.S. Publication No. 2003/0217769 (Okada). This rejection is respectfully traversed.

Applicants respectfully submit that Okada is not prior art by virtue of the filing date of the Japanese priority application. It is Applicants' current intention to file a sworn translation of the Japanese priority application. Accordingly, should the Examiner reach this case before a sworn translation has been made part of the record, he is respectfully requested to contact the undersigned.

The dependent claims are also submitted to be patentable because they set forth additional aspects of the present invention and are dependent from the independent claim discussed above. Therefore, separate and individual consideration of each dependent claim is respectfully requested.

The application is believed to be in condition for allowance, and a Notice of Allowance is respectfully requested.

Applicants' undersigned attorney may be reached in our Costa Mesa, California office by telephone at (714) 540-8700. All correspondence should be directed to our address given below.

Respectfully submitted,



Damond E. Vadnais
Attorney for Applicants
Registration No. 52,310

FITZPATRICK, CELLA, HARPER & SCINTO
30 Rockefeller Plaza
New York, New York 10112-3800
Facsimile: (212) 218-2200

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